

Substitute Form PTO-1449 (Modified)		U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 66302-006US1	Application No. 10/536,512
<b>Information Disclosure Statement by Applicant</b> (Use several sheets if necessary)		Applicant Jae-Hyun Kim		
		Filing Date May 25, 2005	Group Art Unit 1752	
(37 CFR §1.98(b))				

<b>U.S. Patent Documents</b>							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
/SL/	AA	6,033,830	03/07/2000	Sinta et al.	430	325	
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

<b>Foreign Patent Documents or Published Foreign Patent Applications</b>							
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation Yes _____ No _____
/SL/	AL	WO00/54105	09/14/2000	WIPO	-----	-----	
	AM						
	AN						
	AO						
	AP						

<b>Other Documents (include Author, Title, Date, and Place of Publication)</b>		
Examiner Initial	Desig. ID	Document
/SL/	AQ	Hwang S-H et al., "A novel organic bottom anti-reflective coating material for 193nm excimer laser lithography," Polymer, Elsevier Science Publishers B.V, GB, Vol. 41, No 17, August 2000 (2000-08), pages 6691-6694, XP004196891.
	AR	
	AS	
	AT	

Examiner Signature <i>/Sin Lee/</i>	Date Considered 02/15/2008
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

Substitute Disclosure Form (PTO-1449)

CONSIDERED: /SL/